

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In Re Application of:)
)
Nozawa et al.)
)
Serial No.: 10/667,823)
)
Filed: September 22, 2003)
)
For: Phase Mask Shift Blank, Photo Mask Blank,)
And Manufacturing Apparatus And Method)
Of Blanks)
)
Examiner: Rodney Glenn McDonald)
)
Confirmation No.: 1017)
)
Art Unit: 1753)

Commissioner of Patents
P. O. Box 1450
Alexandria, VA 22313-1450

AMENDMENT D

Dear Sir:

In response to the Office Action of July 19, 2006, please amend the above-identified application as follows: